

OVERVIEW OF IP ACTIVITIES

Table 1: Overview of total (resident plus abroad) IP activity by origin, 2012

Origin	Patents	Marks	Designs
China	1	2	1
Germany	5	1	2
United States of America	3	3	5
France (5)(7)	6	5	4
United Kingdom (6)	7	4	6
Italy	11	6	3
Japan (5)(7)	2	10	9
Switzerland	8	8	7
Republic of Korea	4	16	10
Netherlands	10	9	13
Spain	19	7	8
Austria	17	11	12
Sweden	13	15	15
Poland (6)	24	14	11
Turkey	25	13	14
Russian Federation	9	12	31
Belgium	18	18	17
Canada	12	19	23
Finland	15	24	20
India	14	17	29
Denmark	21	23	16
Australia	20	20	21
Brazil	23	21	26
Czech Republic	35	22	19
Luxembourg	32	26	25
Portugal	43	27	18
Norway (5)(6)	26	35	27
China, Hong Kong SAR	39	28	22
Israel (6)	16	49	28
Ireland (5)(6)	28	29	37
Ukraine	29	33	36
Mexico	33	25	46
Romania	41	31	32
Hungary	37	34	33
Bulgaria	56	32	24
New Zealand	30	43	40
Singapore	27	44	45
Greece (5)	44	36	38
South Africa	38	42	41
Thailand	40	40	44
Slovenia (4)(5)(6)	52	45	30
Argentina	45	30	56
Cyprus	54	38	39
Slovakia	58	41	34
Malaysia (2)	34	54	50
Viet Nam	55	37	48
Belarus	31	47	63
Liechtenstein (4)(5)(6)	46	62	35
Chile	48	39	68
Estonia (6)	63	50	43
Croatia (1)	57	61	42
Morocco	69	52	47
Latvia	59	60	54
Malta	65	48	61
Lithuania	70	57	49
United Arab Emirates (4)(5)(6)	68	58	53
Colombia	61	46	74
Philippines	66	53	65
Egypt (5)(6)	47	79	60
Saudi Arabia (1)(3)(5)	42	74	72
Iceland	62	70	62
Republic of Moldova	75	71	52
Monaco	85	55	59
Serbia	67	64	69
Armenia	71	80	51
Pakistan	81	56	66
Bangladesh	88	65	55
Uzbekistan	64	69	75
Algeria	77	77	58
Kazakhstan (1)(5)	36	89	87
Bermuda (4)(5)(6)	84	73	57
Azerbaijan	50	76	94
Barbados	60	91	70
Peru	89	51	84
Bahamas (4)(5)(6)	79	66	82
Costa Rica	97	67	64
Venezuela (1)(2)(6)	87	59	90
Indonesia (1)(5)(6)	51	93	99
Georgia	74	96	78
Jordan	86	75	96
T F Y R of Macedonia (1)(5)	99	84	76
Panama	110	63	86
D.P.R. of Korea (5)(6)	22	137	108
Uruguay	95	68	105
San Marino (4)(5)(6)	112	78	80
Seychelles (2)(4)(6)	81	97	92
Lebanon (4)(5)(6)	104	86	82
Iran (Islamic Republic of)(4)(5)(6)	90	82	100
Kenya (5)	76	119	85
Tunisia (4)(5)(6)	101	99	81
Sri Lanka (4)(5)(6)	109	102	71
Qatar (5)(6)	94	92	98
Yemen (2)(3)	99	85	104
Cuba	73	103	115
Mauritius (4)(5)(6)	96	98	..
Ecuador (4)(5)(6)	126	101	67
Kyrgyzstan	78	125	94
Kuwait (4)(5)(6)	80	106	118
Jamaica (1)(3)(5)	114	94	97
China, Macao SAR	113	100	92

Note: The ranking are based on total number of applications by origin. Patents data refer number of equivalent patent applications. Marks data refer to number of equivalent trademark applications based on class count (i.e. number of classes contained in applications). Designs data refer to number of equivalent industrial design applications based on design count (i.e. number of designs contained in applications). D.P.R. of Korea = Democratic People's Republic of Korea. The table reports origins for which at least two types of IP data are available.

- (1) 2011 patent data.
- (2) 2011 trademark data.
- (3) 2011 industrial design data.
- (4) Data on patent applications at the national IP office are not available. However, applications at the regional IP office are included.
- (5) Data on trademark applications at the national IP office are not available. However, applications at the regional IP office are included.
- (6) Data on industrial design applications at the national IP office are not available. However, applications at the regional IP office are included.
- (7) Trademark data are estimated.

Table 2: Overview of resident IP activity by origin, 2012

Origin	Patents	Marks	Designs
China	1	1	1
Japan (5)(7)	2	3	6
Germany	5	5	2
Republic of Korea	4	9	3
France (5)(7)	7	2	7
United States of America	3	4	9
Turkey	15	6	4
Italy	9	12	5
India	10	7	11
United Kingdom (6)	8	11	10
Russian Federation	6	8	15
Spain	16	13	8
Brazil	17	10	14
Switzerland	12	20	12
Netherlands	13	18	18
Poland (6)	18	19	17
Austria	20	26	13
Australia	24	16	20
Ukraine	25	23	16
Sweden	14	28	23
Mexico	31	15	25
Canada	19	14	41
Thailand	36	25	22
Czech Republic	37	22	24
Belgium	23	32	28
Portugal	41	29	19
Denmark	22	43	26
Viet Nam	46	21	29
Finland	21	41	34
Romania	35	30	32
Argentina	39	17	42
New Zealand	29	37	33
Belarus	26	35	48
South Africa	43	31	37
China, Hong Kong SAR	58	27	27
Malaysia (2)	32	42	40
Morocco	55	39	21
Bulgaria	49	40	30
Hungary	38	45	38
Singapore	33	48	45
Israel (6)	30	59	..
Chile	48	24	65
Colombia	53	33	54
Luxembourg	45	51	46
Kazakhstan (1)(5)	28	..	67
Philippines	60	36	47
Slovakia	54	46	44
Saudi Arabia (1)(3)(5)	47	..	50
Croatia (1)	51	54	43
Greece (5)	40	73	36
Uzbekistan	49	50	53
Bangladesh	71	47	35
Ireland (5)(6)	34	62	58

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Pakistan	69	38	49
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Republic of Moldova	68	60	31
Algeria	65	58	39
Peru	73	34	62
Latvia	52	61	59
Lithuania	63	56	60
Serbia	55	63	63
Venezuela (1)(2)(6)	83	44	..
Georgia	62	74	56
Kenya (5)	64	..	64
Liechtenstein (4)(5)(6)	55	..	74
Estonia (6)	72	64	61
Azerbaijan	59	57	81
Slovenia (4)(5)(6)	67	80	51
Cyprus	75	71	52
Armenia	61	69	71
Iceland	70	72	69
Jordan	76	65	74
Sudan (4)	..	78	66
Panama	..	52	93
T F Y R of Macedonia (1)(5)	80	..	68
Costa Rica	91	49	82
Kyrgyzstan	66	88	70
Uruguay	87	55	85
Monaco	86	67	78
Malta	85	75	73

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